



FORM PTO-1449 INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)	Docket Number (Optional) 637.0015USX	Application Number 10/060,909
	Applicant Antoni, et al.	
	Filing Date January 30, 2002	Group Art Unit 2872

U. S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	4,294,538	10/13/81	Ban	355	51	
<i>RDS</i>	5,222,112	6/22/93	Terasawa et al.	378	34	
	5,669,708	9/23/97	Mashima et al.	362	341	
<i>RDS</i>	5,993,010	11/30/99	Ohzawa et al.	353	99	
<i>RDS</i>	5,995,582	11/30/99	Terashima et al.	378	34	

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FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
<i>RDS</i>	0066295B1	12/8/82	Europe			X	
<i>RDS</i>	0939341A2	9/1/99	Europe			X	
<i>RDS</i>	0985976A2	3/15/00	Europe			X	
<i>RDS</i>	1026547A2	8/9/00	Europe			X	

OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, Etc.)

<i>RDS</i>	Illumination Optics Design for EUV Lithography, M. Antoni et al, SPIE Vol. 4146, p25-34 (2000)

EXAMINER <i>RDS</i>	DATE CONSIDERED <i>9/08/03</i>
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP §609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.